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Docket No.: M4065.0531/P531-A
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Werner Juengling, et al.

Examiner: Walter Lee Lindsay, Jr.

Application No.: 10/673,362

Group Art Unit: 2812

Filed: September 30, 2003

For: REVERSE METAL PROCESS FOR
CREATING A METAL SILICIDE
TRANSISTOR GATE STRUCTURE

RESPONSE TO RESTRICTION REQUIREMENT

U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Dear Sir:

In response to the Restriction Requirement set forth in the Office Action mailed September 8, 2004, Applicants hereby elect Group I, claims 22-33 and 70-86, for continued examination without traverse.

An action on the merits of all the claims and a Notice of Allowance thereof are respectfully requested.

Dated: September 21, 2004

Respectfully submitted,

By 

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